## Notice of References Cited Application/Control No. 10/584,501 Examiner M GOOD JOHNSON Applicant(s)/Patent Under Reexamination MEINDS ET AL. Page 1 of 1

## U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	Α	US-6,985,156	01-2006	Wang et al.	345/582
	В	US-			
	O	US-			
	ם	US-			
	Е	US-			
	F	US-			
	O	US-			
	Ι	US-			
	_	US-			
	٦	US-			
	K	US-			
	┙	US-			
	М	US-			

## FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	0					
	Р					
	Ø					
	R					
	Ø					
	Т					

## **NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)		
	C	Ren et al., Object Space EWA Surface Splatting: A Hardware Accelerated Approach to High Quality Point Rendering, pages 461-470, EUROGRAPHICS, Volume 21, 2002.		
	٧			
	w			
	x			

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.